

# SUPERCritical CPD MEMS DRYER FOR 8" WAFERS **AUTOMEGASAMDRI®-916B, SERIES C**

*UNPARALLELED VERSATILITY AND LOW LCO<sub>2</sub> CONSUMPTION*



**tousimis**

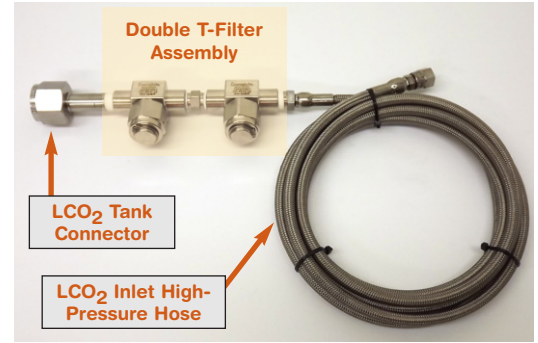
• The New Supercritical Automegasamdri®-916B, Series C System was developed by Dr. A. J. Tousimis and our team of long-standing associates within the tousimis® SAMDRI design group.

• Smooth operation and precise control are the Supercritical Automegasamdri®-916B's trademark; wafer holders and inserts are provided that allow flexible CPD processing of 8", 6", 4", 3", 2" wafers as well as 10mm square die.

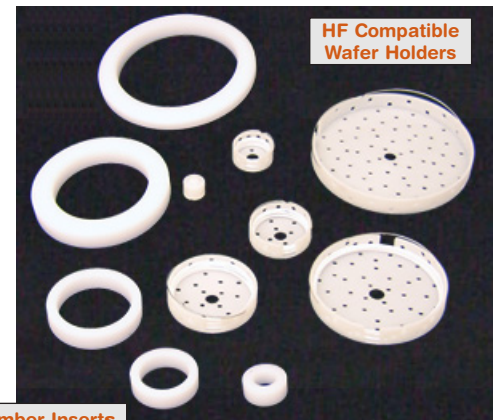
- 40% Less LCO<sub>2</sub> Consumption.<sup>1</sup>
- Process up to 5 wafers in Less than 1 hour.
- All inclusive Small Foot Print design.
- Minimal installation Site Preparation required.
- On Site Start-Up and User Training included.<sup>2</sup>

## FEATURES

- High efficiency internal closed loop refrigeration.\* (22°C to operational in less than 5 minutes)!
- Post-Purge-Filter easily accessible for maintenance ease.\*
- The patented internal SOTER™ condenser\* quietly captures and separates CO<sub>2</sub> exhaust and waste alcohols.
- Unique chamber inserts\* enable variance of chamber I.D. maximizing efficiency in LCO<sub>2</sub> consumption, process time, and providing multiple size wafer process capability!
- Process up to 5 x 8" wafers per process run. Also comes with additional HF Compatible Wafer Holders\* to process 5 x 6", 5 x 4", 5 x 3", 5 x 2" diameter wafers or 5 x 10mm square die (tousimis® HF compatible Wafer Holders\* may be used to etch and process your wafers minimizing handling).
- Chamber illumination with viewing window facilitates chamber status visualization.\*
- Microprocessor controller allows for completely automatic processing.\*
- All internal surfaces are inert to CO<sub>2</sub> and ultrapure alcohols.
- Repeatable operating parameters insuring "reproducibility" of results.
- Static pressure control module helps insure automatic safe pressure stability.
- Internal filtration system delivers clean LCO<sub>2</sub> into process chamber down to 0.08µm.
- Control panel LED's instantly indicate process mode at a glance.
- Clean room static-free compatible design.
- All electronic components meet CE, UL and/or U.S. Military Specifications.



Standard Accessories



Chamber Inserts

Standard Accessories

## SPECIFICATIONS

- Cabinet: 19.8" (50.3cm) Width x 31.7" (80.6cm) Depth x 44.5" (113.0cm) Height
- System Set-Up Area Footprint: 27" (68.6cm) Width x 38" (96.5cm) Depth
- Chamber size: 8.50" I.D. x 1.25" Depth / Chamber volume: 1162 ml
- Temperature gauge range: -30°C to 60°C, Pressure gauge range: 0 to 2,000 psi
- 120V / 50-60Hz (Other voltage units also available. Please Inquire)
- LCO<sub>2</sub> flow is precisely controlled through Micro Metering Valves with Vernier handles for adjustment ease.\*

## STANDARD ACCESSORIES

- LCO<sub>2</sub> High Pressure braided stainless steel inert Teflon® lined hose. 10ft (~ 3m) long for clean room operation (at a nominal charge, other lengths available upon request).
- Double T-Filter Assembly (#8785) pre-installed onto the chamber LCO<sub>2</sub> supply high-pressure hose. Flows LCO<sub>2</sub> twice thru 0.5 µm filters with 99.5% particulate retention prior to LCO<sub>2</sub> entering Automegasamdri®-916B.
- Tool set included for connecting LCO<sub>2</sub> chamber supply line
- Static free exhaust tubing for all exhaust outlets.
- Internal stainless and nickel scintered filtration systems incorporated to protect lines, wafers, and valves down to 0.4µm.
- Spare chamber O-rings (3), chamber lamps (2), and slo-blow fuses (2x3A and 2x8A).
- Complete wafer size process flexibility! 5 chamber inserts\* enable 8.5" chamber I.D. reduction down to smaller chamber I.D. sizes for processing wafers and die from a range including: 8", 6", 4", 3", 2", and 1.25" ! Allows for multiple wafer size drying.
- 8", 6", 4", 3", 2" diameter wafer holders and 10mm square die holders included. Holders are HF compatible and can hold up to 5 wafers or die each.
- 2 year warranty on all parts and labor. Free lifetime technical support consultations by our scientific staff.

<sup>1</sup> Compared with tousimis Automegasamdri®-916B, Series B

<sup>2</sup> Available for most countries. Contact tousimis for details.

\* Most Automegasamdri® feature U.S. patents (#6,493,964, #6,678,968) or patents pending.

*Note: Actual delivered model or accessories may vary slightly, as advancements are being constantly applied.*